Notice of Allowability	Application No.	Applicant(s)
	10/605,653	YU ET AL.
	Examiner	Art Unit
	Jason M. Han	2875
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.		
1. This communication is responsive to 21 May 2006 and the telephone converation on 21 July 2006.		
2. The allowed claim(s) is/are <u>1,9 and 11-17</u> .		
 3. Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some* c) None of the: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. 3. Copies of the certified copies of the priority documents have been received in this national stage application from the International Bureau (PCT Rule 17.2(a)). * Certified copies not received: 		
Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application. THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		
4. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.		
5. CORRECTED DRAWINGS (as "replacement sheets") must be submitted.		
(a) ☐ including changes required by the Notice of Draftsperson's Patent Drawing Review (PTO-948) attached		
1) 🗌 hereto or 2) 🔲 to Paper No./Mail Date		
(b) ☐ including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date		
Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d).		
6. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.		
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Attachment(s)	5	Potent Application (PTO 152)
 Notice of References Cited (PTO-892) Notice of Draftperson's Patent Drawing Review (PTO-948) 	6. ⊠ Interview Summary	Patent Application (PTO-152) (PTO-413)
	Paper No./Mail Da	ite <u>20060721</u> .
 Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date 20060720 	8), 7. ⊠ Examiner's Amend	ment/Comment
4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	8. 🛛 Examiner's Statem	ent of Reasons for Allowance
	9.	

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DETAILED ACTION

EXAMINER'S AMENDMENT

1. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with Winston Hsu on July 21, 2006.

The application has been amended as follows:

- a. Claim 1, Replace: "a plurality of scattering apertures installed on the surface of the diffusing plate opposite to the plurality of point light source generators, wherein one or more scattering pattern is disposed over the inner wall of at least one scattering aperture, and the scattering aperture is trapezoidal in shape" with -- a plurality of scattering apertures installed on the surface of the diffusing plate opposite to the plurality of point light source generators, wherein a plurality of scattering patterns are disposed over the inner wall of at least two scattering apertures, and the scattering patterns are different patterns --
- b. Claim 17, Replace: "a plurality of scattering apertures installed on the surface of the diffusing plate facing the plurality of point light source generators, wherein a plurality of scattering pattern is disposed over the inner wall of at least one scattering aperture, and the scattering patterns are different patterns -- a plurality of scattering apertures installed on the surface of the diffusing plate

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facing the plurality of point light source generators, wherein a plurality of scattering patterns are disposed over the inner wall of at least two scattering apertures, and the scattering patterns are different patterns --

Allowable Subject Matter

- 2. Claims 1, 9, and 11-17 are allowed.
- 3. The following is an examiner's statement of reasons for allowance:

With regard to Independent Claims 1 and 17, the Applicant has sufficiently claimed and defined a backlight module incorporating a diffusing plate with a plurality of scattering particles formed therein and having a plurality of scattering apertures installed on top of a plurality of point light source generators, wherein a plurality of different scattering patterns are disposed over the inner wall of at least two scattering apertures. The prior art of record fails to teach of suggest the combination of structural limitations claimed herein, specifically to the abovementioned characteristics of the diffusing plate and a diffusing sheet installed thereabove, and all subsequent dependent claims are allowed.

4. Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

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Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jason M. Han whose telephone number is (571) 272-2207. The examiner can normally be reached on 8:00am-5:00pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Sandra O'Shea can be reached on (571) 272-2378. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Jason M Han Examiner Art Unit 2875

JMH (7/21/2006)

THOMAS M. SEMBER
PRIMARY EXAMINER